

# WEST Search History

DATE: Wednesday, May 07, 2003

## Set Name Query

side by side

## Hit Count Set Name

result set

*DB=DWPI; PLUR=YES; OP=ADJ*

L12	L11 and (cover or gap)	23	L12
L11	L10 and (resist or film or layer or coating)	196	L11
L10	L9 and ((edge or peripher\$2) SAME (remov\$3 or etch\$3 or eliminat\$3))	255	L10
L9	photomask or (phase ADJ shift\$2)	36956	L9

*DB=USPT,PGPB,JPAB,EPAB; PLUR=YES; OP=ADJ*

L8	L7 and cover.clm.	279	L8
L7	L6 and cover	1162	L7
L6	L5 and (film or coating or resist or photoresist).clm.	2479	L6
L5	L4 and (edge or peripher\$2).clm.	3400	L5
L4	L3 and ((edge or peripher\$2) SAME (film or coating or resist or photoresist))	9653	L4
L3	L2 and ((edge or peripher\$2) SAME (remov\$3 or etch\$3 or dissolv\$3 or eliminat\$3))	15102	L3
L2	L1 and (film or layer or coating or resist or photoresist)	200328	L2
L1	(118/\$ OR 216/\$ OR 427/\$ OR 430/\$).CCLS.	299898	L1

END OF SEARCH HISTORY